



*TRW/J.*  
**PATENT**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 10/712,775

Group Art Unit: 1765

Filing Date: November 14, 2003

Examiner: Anita K. Alanko

Applicant: Donggyun Han et al.

Title: APPARATUS AND METHOD FOR REMOVING  
PHOTORESIST FROM A SUBSTRATE

Attorney Docket: 2557-000216/US

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Customer Service Window

December 29, 2005

Randolph Building

401 Dulany Street

Alexandria, VA 22314

**Mail Stop Amendment**

**AMENDMENT**

Sir:

In response to the Office Action mailed September 29, 2005, the following amendments and remarks are respectfully submitted in connection with the above-identified application.

**Amendments to the Claims** begin on page 2 of this Amendment.

**Remarks** begin on page 8 of this Amendment.

|             | Claims remaining after<br>Amendment |   | Highest number<br>previously paid for |   | Present extra |
|-------------|-------------------------------------|---|---------------------------------------|---|---------------|
| Total       | 40                                  | - | 50                                    | = | 0             |
| Independent | 3                                   | - | 4                                     | = | 0             |